Σ3{111}対称傾角粒界の不純物偏析能とキャリア再結合速度に対する 傾角のずれの影響

Impact of the deviation of the tilt angle on the recombination activity and the impurity segregation ability of Σ 3{111} symmetric tilt boundaries

東北大金研¹, 阪大産研², 東北大金研大洗センター³, 名古屋大工⁴ ^O大野裕¹, 沓掛健太朗¹, 玉岡武泰², 竹田精治², 清水康雄³, 海老澤直樹³, 井上耕治³, 永井康介³, 宇佐美徳隆⁴

IMR, Tohoku Univ.¹, The Oarai Center, IMR, Tohoku Univ.², ISIR, Osaka Univ.³, GSE, Nagoya Univ.⁴,

°Yutaka Ohno^{1,*}, Kentaro Kutsukake¹, Takehiro Tamaoka², Seiji Takeda², Yasuo Shimizu³,

Naoki Ebisawa³, Koji Inoue³, Yasuyoshi Nagai³, Noritaka Usami⁴

E-mail: yutakaohno@imr.tohoku.ac.jp

Grain boundaries (GBs) are inevitably introduced in polycrystalline silicon (Si) ingots for solar cells, and they have substantial influences on electronic properties such as carrier recombination activity, via the segregation of impurity atoms. Especially, asymmetric GBs with higher- Σ value of the associated coincident site lattice (CSL) are frequently introduced in Si ingots, and they severely affect the overall material properties even when their density is very low. Therefore, a comprehensive knowledge of the recombination activity of the GBs, as well as their impurity segregation ability depending on their atomistic structure, is indispensable to produce cost-effective high-efficiency solar cells by controlling the formation of detrimental GBs.

In the present study, we discuss the recombination activity of asymmetric $\Sigma 3$ {111} GBs with the <110> tilt axis, whose GB planes are slightly inclined from {111}. Even though the activity is negligible for the symmetric $\Sigma 3$ {111} GBs of which the GB plane is just on {111} [1], the activity is high for the asymmetric $\Sigma 3$ {111} GBs even when their inclination angle is small. High-angle annular dark-field scanning transmission electron microscopy (HAADF-STEM) reveals that, most segments of the asymmetric GBs are composed of arrays of GB dislocations lying on symmetric $\Sigma 3$ {111} GBs. Those dislocations are edge-type with the Burgers vector of 1/3<111>. Atom probe tomography (APT) reveals that oxygen atoms would segregate at the atomic sites under tensile stress above about 2 GPa, which are introduced along the GB plane due to the GB dislocations [2-4]. Carbon atoms also segregate, while they would locate only nearby the dislocation cores. The correlation between the recombination activity and the segregation ability of impurity atoms will be discussed.

[1] Y. Ohno, *et al.*, Appl. Phys. Lett. **103** (2013) 102102. [2] Y. Ohno, *et al.*, Appl. Phys. Lett. **106** (2015) 251603.
[3] Y. Ohno, *et al.*, Appl. Phys. Lett. **110** (2017) 062105. [4] Y. Ohno, *et al.*, J. Microsc. **268** (2017) 230.

Acknowledgments: This work was partly supported by "Multicrystalline informatics toward establishment of general grain boundary physics & realization of high-quality silicon ingot with ideal microstructures" project in JST/CREST, Grant No. JPMJCR17J1 (2017-2023).